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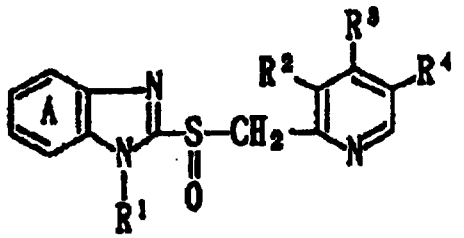
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(54) Title: CRYSTALS OF BENZIMIDAZOLE DERIVATIVES AND THEIR PRODUCTION

(57) Abstract

A substantially solvent–free and stable crystal of the compound of formula (I) wherein the ring A may optionally be substituted, R^1 represents hydrogen or an N–protecting group, each of R^2, R^3 and R^4 is (1) a hydrogen atom, (2) an alkyl group which may optionally be substituted with halogen atom(s) or (3) an alkoxy group which may optionally be substituted with halogen atoms(s) or alkoxy; or its salt, is produced by subjecting a solvate of the compound (I) or its salt to de–solvent treatment, in an industrially advantageous method.



(I)